Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1. (Previously presented) A thermosetting resin composition comprising at least a polyimide resin component (A) containing at least one polyimide resin, a phenol resin component (B) containing at least one phenol resin, and an epoxy resin component (C) containing at least one epoxy resin, wherein the mixing ratio by weight (A)/[(B)+(C)] is in a range of 0.4 to 2.0, the mixing ratio by weight being the ratio of the weight of the polyimide resin component (A) to the total weight of the phenol resin component (B) and the epoxy resin component (C), wherein the polyimide resin (A) is produced by reacting an acid dianhydride component with a diamine component or an isocyanate component, and the acid dianhydride component contains at least an acid dianhydride represented by general formula (1):

wherein V represents a direct bond, --O--,--O-T-O--,--(C=O)--,--C(CF₃)₂--, or -- $C(CH_3)_{2}$ --, T representing a divalent organic group.

2. (Previously Presented) The thermosetting resin composition according to claim 1, wherein the mixing ratio by mole (B)/(C) is in a range of 0.4 to 1.2, the mixing ratio by mole being the ratio of the number of moles of the hydroxyl group of the phenol resin contained in the phenol resin component (B) to the number of moles of the epoxy group of the epoxy resin contained in the epoxy resin component (C).

Attorney Docket No. 81844.0044 Customer No. 26021

3. (Previously Presented) The thermosetting resin composition according to claims 1 or 2, wherein the polyimide resin (A) contains a soluble polyimide resin.

4. (Previously Presented) The thermosetting resin composition according to claim 3, wherein the polyimide resin (A) dissolves in an amount of 1% by weight or more in at least one organic solvent selected from the group consisting of dioxolane, dioxane, tetrahydrofuran, N,N-dimethylformamide, N,N-dimethylacetamide, and N-methyl-2-pyrrolidone in a temperature range of 15°C to 100°C.

5. (Previously Presented) The thermosetting resin composition according to claim 4, wherein the polyimide resin (A) contains at least one component for imparting organic solvent solubility which is selected from the group consisting of an aliphatic compound component, an alicyclic compound component, and a bisphenol compoundalkylene oxide adduct component, so as to exhibit solubility in a mixed solvent containing a low-boiling organic solvent.

6. (Canceled)

7. (Previously presented) A thermosetting resin composition comprising at least a polyimide resin component (A) containing at least one polyimide resin, a phenol resin component (B) containing at least one phenol resin, and an epoxy resin component (C) containing at least one epoxy resin, wherein the mixing ratio by weight (A)/[(B)+(C)] is in a range of 0.4 to 2.0, the mixing ratio by weight being the ratio of the weight of the polyimide resin component (A) to the total weight of the phenol resin component (B) and the epoxy resin component (C), wherein the polyimide resin (A) is produced by reacting

an acid dianhydride component with a diamine component or an isocyanate component, and the acid dianhydride component contains at least an acid dianhydride represented by general formula (1):

wherein V represents a direct bond, --O--,-- $C(CF_3)_2$ --, or -- $C(CH_3)_2$ --, T representing a divalent organic group

wherein the polyimide resin (A) is produced by reacting an acid dianhydride component with a diamine component or an isocyanate component, and the diamine component or the isocyanate component contains at least any one of a siloxane diamine, a diamine containing a hydroxyl group and/or a carboxyl group, a diamine having amino groups at the meta positions, a diamine having amino groups at the ortho positions, an isocyanate having an amino group at the meta position, and an isocyanate having an amino group at the ortho position.

8. (Previously presented) A thermosetting resin composition comprising at least a polyimide resin component (A) containing at least one polyimide resin, a phenol resin component (B) containing at least one phenol resin, and an epoxy resin component (C) containing at least one epoxy resin, wherein the mixing ratio by weight (A)/[(B)+(C)] is in a range of 0.4 to 2.0, the mixing ratio by weight being the ratio of the weight of the polyimide resin component (A) to the total weight of the phenol resin component (B) and the epoxy resin component (C), wherein the phenol resin component (B) contains at least one phenol resin selected from the group consisting of compounds having structures represented by the formulae:

wherein a, b, c, and d, each represent an integer of 1 to 10.

9. (Previously presented) A thermosetting resin composition comprising at least a polyimide resin component (A) containing at least one polyimide resin, a phenol resin component (B) containing at least one phenol resin and an epoxy resin component (C) containing at least one epoxy resin, wherein the mixing ratio by weight (A)/[(B)+(C)] is in a range of 0.4 to 2.0, the mixing ratio by weight being the ratio of the weight of the polyimide resin component (A) to the total weight of the phenol resin component (B) and the epoxy resin component (C), wherein the epoxy resin component (C) contains at least one epoxy resin selected from the group consisting of compounds having structures represented by the formulae:

Appl. No. 10/552,540

Amdt. Dated February 19, 2008

Reply to Office Action of November 16, 2007

Attorney Docket No. 81844.0044 Customer No. 26021

wherein g, h, i, j, and k each represent an integer of 1 to 10.

10. (Original) A thermosetting resin composition comprising at least a polyimide

resin (A) containing at least one polyimide resin, a phosphazene compound (D)

containing at least one phosphazene compound, and a cyanate ester compound (E)

containing at least one cyanate ester compound, wherein the phosphazene compound

(D) comprises a phenolic hydroxyl group-containing phenoxyphosphazene compound

(D-1) and/or a crosslinked phenoxyphosphazene compound (D-2) prepared by

crosslinking the phenoxyphosphazene compound (D-1), the crosslinked

phenoxyphosphazene compound (D-2) having at least one phenolic hydroxyl group.

11. (Previously Presented) The thermosetting resin composition according to

claim 10, wherein the mixing ratio by weight (D)/[(A)+(D)+(E)] is in a range of 0.01 to

0.4, the mixing ratio by weight being the ratio of the weight of the phosphazene

compound (D) to the total weight of the polyimide resin (A), the phosphazene compound

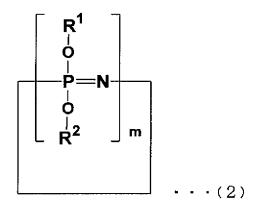
(D), and the cyanate ester compound (E).

12. (Previously Presented) The thermosetting resin composition according to

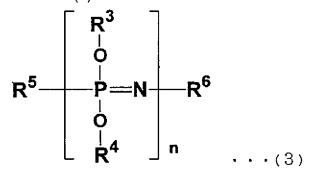
claims 10 or 11, wherein the phenoxyphosphazene compound (D-1) comprises at least

a cyclic phenoxyphosphazene compound (D-11) represented by general formula (2):

Page 7 of 28



wherein m represents an integer of 3 to 25; R¹ and R² each represent a phenyl group or a hydroxyphenyl group; and at least one hydroxyphenyl group is contained per molecule and/or a linear phenoxyphosphazene compound (D-12) represented by general formula (3):



wherein n represents an integer of 3 to 10,000; R^3 and R^4 each represent a phenyl group or a hydroxyphenyl group; at least one hydroxyphenyl group is contained per molecule; R^5 represents -N=P(OC₆H₅)₃, -N=P(OC₆H₅)₂(OC₆H₄OH),

- $-N=P(OC_6H_5)(OC_6H_4OH)_2$, $-N=P(OC_6H_4OH)_3$, $-N=P(O)OC_6H_5$, or
- -N=P(O)(OC₆H₄OH); and R⁶ represents -P(OC₆H₅)₄,
- $-P(OC_6H_5)_3(OC_6H_4OH)$, $-P(OC_6H_5)_2(OC_6H_4OH)_2$, $-P(OC_6H_5)(OC_6H_4OH)_3$,
- $-P(OC_6H_4OH)_4$, $-P(O)(OC_6H_5)_2$, $-P(O)(OC_6H_5)(OC_6H_4OH)$, or
- $-P(O)(OC_6H_4OH)_2$.

Reply to Office Action of November 16, 2007

Attorney Docket No. 81844.0044 Customer No. 26021

13. (Previously Presented) The thermosetting resin composition according to claim 12, wherein the crosslinked phenoxyphosphazene compound (D-2) is prepared by crosslinking the phenoxyphosphazene compound (D-1) with a phenylene-based crosslinking group containing at least any one of an o-phenylene group, an m-phenylene group, a p-phenylene group, and a bisphenylene group represented by general formula (4):

$$(R^7)_{\overline{p}}$$

wherein R⁷ represents -C(CH₃)₂-, -SO₂-, -S-, or -O-; and p represents 0 or 1.

14. (Previously Presented) The thermosetting resin composition according to claim 13, wherein the crosslinked phenoxyphosphazene compound (D-2) is a phenylene-based crosslinked phenoxyphosphazene compound (D-21) having at least one phenolic hydroxyl group, in which the cyclic phenoxyphosphazene compound (D-11) and/or the linear phenoxyphosphazene compound (D-12) are used as the phenoxyphosphazene compound, and the phenylene-based crosslinking group lies between two oxygen atoms of the phenoxyphosphazene compound (D-1), the phenyl group and the hydroxyphenyl group being separated from the oxygen atoms, and the content of the phenyl group and the hydroxyphenyl group in the crosslinked phenoxyphosphazene compound is in a range of 50% to 99.9% based on the total number phenyl groups and hydroxyphenyl groups contained of the phenoxyphosphazene compound.

Attorney Docket No. 81844.0044 Customer No. 26021

15. (Previously Presented) The thermosetting resin composition according to

claim 14, wherein the polyimide resin (A) contains a soluble polyimide resin.

16. (Previously Presented) The thermosetting resin composition according to

claim 15, wherein the polyimide resin (A) dissolves in an amount of 1% by weight or

more in at least one organic solvent selected from the group consisting of dioxolane,

dioxane, tetrahydrofuran, N,N-dimethylformamide, N,N-dimethylacetamide, and N-

methyl-2-pyrrolidone in a temperature range of 15°C to 100°C.

17. (Previously Presented) The thermosetting resin composition according to

claim 16, wherein the polyimide resin (A) contains at least one component for imparting

organic solvent solubility which is selected from the group consisting of an aliphatic

compound component, an alicyclic compound component, and a bisphenol compound-

alkylene oxide adduct component, so as to exhibit solubility in a mixed solvent

containing a low-boiling organic solvent.

18. (Previously Presented) The thermosetting resin composition according to

claim 17, wherein the polyimide resin (A) is produced by reacting an acid dianhydride

component with a diamine component or an isocyanate component, and the acid

dianhydride component contains at least an acid dianhydride represented by general

formula (1):

$$0 \longrightarrow 0 \longrightarrow 0$$

$$0 \longrightarrow 0$$

$$0$$

$$0$$

$$0$$

$$0$$

$$0$$

wherein V represents a direct bond, -O-, -O-T-O-,

-O-CO-T-CO-O-, -(C=O)-, -C(CF₃)₂-, or -C(CH₃)₂-, T representing a divalent organic group.

- 19. (Previously Presented) The thermosetting resin composition according to claim 18, wherein the polyimide resin (A) is produced by reacting an acid dianhydride component with a diamine component or an isocyanate component, and the diamine component or the isocyanate component contains at least any one of a siloxane diamine, a diamine containing a hydroxyl group and/or a carboxyl group, a diamine having amino groups at the meta positions, a diamine having amino groups at the ortho positions, an isocyanate having an amino group at the ortho position.
- 20. (Previously Presented) The thermosetting resin composition according to claim 19, wherein the cyanate ester compound (E) includes at least one compound selected from the group consisting of compounds represented by the group of general formulae (1):

Group of general formulae (1)

wherein r represents 0 to 4.

21. (Previously Presented) A multilayer body comprising at least one resin layer

formed of the thermosetting resin composition according to claims 1 or 10.

22. (Previously Presented) The multilayer body according to claim 21, wherein

the multilayer body is used as a circuit board or a multilayer printed circuit board.

23. (Previously Presented) A circuit board comprising a layer having a dielectric

constant of 3.3 or less and a dielectric loss tangent of 0.020 or less in a range of in a

frequency range of 1 to 10 GHz and being formed on wiring boards or circuits, wherein

the layer is obtained by curing a thermosetting resin composition comprising at least a

polyimide resin component (A) containing at least one polyimide resin, a phenol resin

component (B) containing at least one phenol resin, and an epoxy resin component (C)

containing at least one epoxy resin, wherein the mixing ratio by weight (A)/[(B)+(C)] is in

a range of 0.4 to 2.0, the mixing ratio by weight being the ratio of the weight of the

polyimide resin component (A) to the total weight of the phenol resin component (B) and

the epoxy resin component (C).

24. (Currently Amended) The thermosetting resin composition circuit board

according to claim 23, wherein the mixing ratio by mole (B)/(C) is in a range of 0.4 to

1.2, the mixing ratio by mole being the ratio of the number of moles of the hydroxyl

group of the phenol resin contained in the phenol resin component (B) to the number of

Page 13 of 28

Amdt. Dated February 19, 2008

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Reply to Office Action of November 16, 2007

moles of the epoxy group of the epoxy resin contained in the epoxy resin component

(C).

25. (Currently Amended) The thermosetting resin composition circuit board

according to claims 23 or 24, wherein the polyimide resin (A) contains a soluble

polyimide resin.

26. (Currently Amended) The thermosetting resin composition circuit board

according to claim 25, wherein the polyimide resin (A) dissolves in an amount of 1% by

weight or more in at least one organic solvent selected from the group consisting of

dioxolane, dioxane, tetrahydrofuran, N,N-dimethylformamide, N,N-dimethylacetamide,

and N-methyl-2-pyrrolidone in a temperature range of 15°C to 100°C.

27. (Currently Amended) The thermosetting resin composition circuit board

according to claim 26, wherein the polyimide resin (A) contains at least one component

for imparting organic solvent solubility which is selected from the group consisting of an

aliphatic compound component, an alicyclic compound component, and a bisphenol

compound-alkylene oxide adduct component, so as to exhibit solubility in a mixed

solvent containing a low-boiling organic solvent.

28. (Currently Amended) The thermosetting resin composition circuit board

according to claim 27, wherein the polyimide resin (A) is produced by reacting an acid

dianhydride component with a diamine component or an isocyanate component, and

Page 14 of 28

\\LA - 081844/000044 - 367492 v1

the acid dianhydride component contains at least an acid dianhydride represented by general formula (1):

$$0 \longrightarrow V \longrightarrow 0 \longrightarrow 0$$

wherein V represents a direct bond, -O-, -O-T-O-,

-O-CO-T-CO-O-, -(C=O)-, -C(CF₃)₂-, or -C(CH₃)₂-, T representing a divalent organic group.

- 29. (Currently Amended) The thermosetting resin composition circuit board according to claim 28, wherein the polyimide resin (A) is produced by reacting an acid dianhydride component with a diamine component or an isocyanate component, and the diamine component or the isocyanate component contains at least any one of a siloxane diamine, a diamine containing a hydroxyl group and/or a carboxyl group, a diamine having amino groups at the meta positions, a diamine having amino groups at the ortho positions, an isocyanate having an amino group at the meta position, and an isocyanate having an amino group at the ortho position.
- 30. (Currently Amended) The thermosetting resin composition circuit board according to claim [[29]] 23, wherein the phenol resin component (B) contains at least

one phenol resin selected from the group consisting of compounds having structures represented by the formulae:

OH OH CH₃

$$C = H_2$$

$$A = H_2$$

$$C = H_2$$

$$C$$

wherein a, b, c, d, and e each represent an integer of 1 to 10.

31. (Currently Amended) The thermosetting resin composition circuit board according to claim [[30]] 23, wherein the epoxy resin component (C) contains at least

Attorney Docket No. 81844.0044 Customer No. 26021

one epoxy resin selected from the group consisting of compounds having structures represented by the formulae:

Appl. No. 10/552,540

32.

Amdt. Dated February 19, 2008

Reply to Office Action of November 16, 2007

Attorney Docket No. 81844.0044 Customer No. 26021

wherein **g**, **h**, **i**, **j**, and **k** each represent an integer of 1 to 10.

according to claim 23, further comprising a layer having a dielectric constant of 3.3 or less and a dielectric loss tangent of 0.020 or less in a frequency range of 1 to 10 GHz and being formed on wiring boards or circuits, wherein the layer is obtained by curing a thermosetting resin composition comprising at least a polyimide resin (A) containing at least one polyimide resin, a phosphazene compound (D) containing at least one phosphazene compound, and a cyanate ester compound (E) containing at least one

(Currently Amended) A thermosetting resin composition A circuit board

cyanate ester compound, wherein the phosphazene compound (D) comprises a

phenolic hydroxyl group-containing phenoxyphosphazene compound (D-1) and/or a

crosslinked phenoxyphosphazene compound (D-2) prepared by crosslinking the

phenoxyphosphazene compound (D-1), the crosslinked phenoxyphosphazene

compound (D-2) having at least one phenolic hydroxyl group.

33. (Currently Amended) The thermosetting resin composition circuit board

according to claim 32, wherein the mixing ratio by weight (D)/[(A)+(D)+(E)] is in a range

of 0.01 to 0.4, the mixing ratio by weight being the ratio of the weight of the

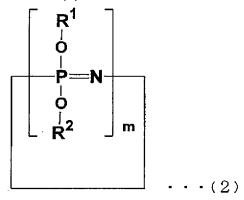
phosphazene compound (D) to the total weight of the polyimide resin (A), the

phosphazene compound (D), and the cyanate ester compound (E).

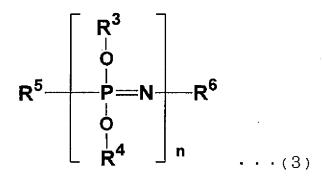
34. (Currently Amended) The thermosetting resin composition circuit board

according to claims 32 or 33, wherein the phenoxyphosphazene compound (D-1)

comprises at least a cyclic phenoxyphosphazene compound (D-11) represented by general formula (2):



wherein m represents an integer of 3 to 25; R¹ and R² each represent a phenyl group or a hydroxyphenyl group; and at least one hydroxyphenyl group is contained per molecule and/or a linear phenoxyphosphazene compound (D-12) represented by general formula (3):



wherein n represents an integer of 3 to 10,000; R^3 and R^4 each represent a phenyl group or a hydroxyphenyl group; at least one hydroxyphenyl group is contained per molecule; R^5 represents -N=P(OC₆H₅)₃, -N=P(OC₆H₅)₂(OC₆H₄OH),

- $-N = P(OC_6H_5)(OC_6H_4OH)_2, \ -N \\ = P(OC_6H_4OH)_3, \ -N \\ = P(O)OC_6H_5, \ or \ -N \\ = P(O)OC_6H$
- -N=P(O)(OC₆H₄OH); and R⁶ represents -P(OC₆H₅)₄,
- $-P(OC_6H_5)_3(OC_6H_4OH), -P(OC_6H_5)_2(OC_6H_4OH)_2, -P(OC_6H_5)(OC_6H_4OH)_3, -P(OC_6H_5)_2(OC_6H_4OH)_3, -P(OC_6H_5)_3(OC_6H_4OH)_4, -P(OC_6H_5)_4(OC_6H_5)_4(OC_6H_5)_4, -P(OC_6H_5)_4(OC_6H_5)_4, -P(OC_6H_5)_4(OC_6H_5)_4, -P(OC_6H_5)_4, -P(OC_6H_5)_5, -P(O$
- $-P(OC_6H_4OH)_4, \ -P(O)(OC_6H_5)_2, \ -P(O)(OC_6H_5)(OC_6H_4OH), \ or$

-P(O)(OC₆H₄OH)₂.

35. (Currently Amended) The thermosetting resin composition circuit board according to claim 34, wherein the crosslinked phenoxyphosphazene compound (D-2) is prepared by crosslinking the phenoxyphosphazene compound (D-1) with a phenylene-based crosslinking group containing at least any one of an o-phenylene group, an m-phenylene group, a p-phenylene group, and a bisphenylene group represented by general formula (4):

$$- (R^7)_{\overline{p}} - \cdots (4)$$

wherein \mathbb{R}^7 represents -C(CH₃)₂-, -SO₂-, -S-, or -O-; and p represents 0 or 1.

36. (Currently Amended) The thermosetting resin composition circuit board according to claim 35, wherein the crosslinked phenoxyphosphazene compound (D-2) is a phenylene-based crosslinked phenoxyphosphazene compound (D-21) having at least one phenolic hydroxyl group, in which the cyclic phenoxyphosphazene compound (D-11) and/or the linear phenoxyphosphazene compound (D-12) are used as the phenoxyphosphazene compound, and the phenylene-based crosslinking group lies between two oxygen atoms of the phenoxyphosphazene compound (D-1), the phenyl group and the hydroxyphenyl group being separated from the oxygen atoms, and the content of the phenyl group and the hydroxyphenyl group in the crosslinked phenoxyphosphazene compound is in a range of 50% to 99.9% based on the total

Appl. No. 10/552,540

Amdt. Dated February 19, 2008

Reply to Office Action of November 16, 2007

Attorney Docket No. 81844.0044 Customer No. 26021

number of phenyl groups and hydroxyphenyl groups contained in the

phenoxyphosphazene compound.

37. (Currently Amended) The thermosetting resin composition circuit board

according to claim 36, wherein the polyimide resin (A) contains a soluble polyimide

resin.

38. (Currently Amended) The thermosetting resin composition circuit board

according to claim 37, wherein the polyimide resin (A) dissolves in an amount of 1% by

weight or more in at least one organic solvent selected from the group consisting of

dioxolane, dioxane, tetrahydrofuran, N,N-dimethylformamide, N,N-dimethylacetamide,

and N-methyl-2-pyrrolidone in a temperature range of 15°C to 100°C.

39. (Currently Amended) The thermosetting resin composition circuit board

according to claim 38, wherein the polyimide resin (A) contains at least one component

for imparting organic solvent solubility which is selected from the group consisting of an

aliphatic compound component, an alicyclic compound component, and a bisphenol

compound-alkylene oxide adduct component, so as to exhibit solubility in a mixed

solvent containing a low-boiling organic solvent.

40. (Currently Amended) The thermosetting resin composition circuit board

according to claim 39, wherein the polyimide resin (A) is produced by reacting an acid

dianhydride component with a diamine component or an isocyanate component, and

Page 22 of 28

the acid dianhydride component contains at least an acid dianhydride represented by general formula (1):

$$0 \longrightarrow V \longrightarrow 0$$

$$0$$

$$0$$

$$0$$

$$0$$

$$0$$

$$0$$

wherein V represents a direct bond, -O-, -O-T-O-,

-O-CO-T-CO-O-, -(C=O)-, -C(CF $_3$) $_2$ -, or -C(CH $_3$) $_2$ -, T representing a divalent organic group.

- 41. (Currently Amended) The thermosetting resin composition circuit board according to claim 40, wherein the polyimide resin (A) is produced by reacting an acid dianhydride component with a diamine component or an isocyanate component, and the diamine component or the isocyanate component contains at least any one of a siloxane diamine, a diamine containing a hydroxyl group and/or a carboxyl group, a diamine having amino groups at the meta positions, a diamine having amino groups at the ortho positions, an isocyanate having an amino group at the meta position, and an isocyanate having an amino group at the ortho position.
- 42. (Currently Amended) The thermosetting resin composition circuit board according to claim 41, wherein the cyanate ester compound (E) includes at least one

Attorney Docket No. 81844.0044 Customer No. 26021

compound selected from the group consisting of compounds represented by the group of general formulae (1):

Group of general formulae (1)

Attorney Docket No. 81844,0044 Customer No. 26021

wherein r represents 0 to 4.